

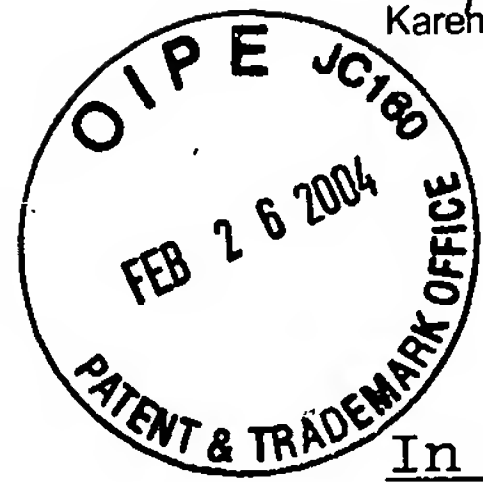
I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to :
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2/24/04
(Date of Deposit)

Karen Cinq-Mars

(Signature)

2/24/04
(Date)



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of _____: February 12, 2004
Liebmann et al. _____:
Serial No. 10/708,055 _____: Examiner:
Filed: 02-05-04 _____: IBM Corporation
Dept. 18G/Bldg. 300-482
Title: METHOD OF CONFLICT AVOIDANCE 2070 Route 52
IN FABRICATION OF GATE-SHRINK Hopewell Junction,
ALTERNATING PHASE SHIFTING MASKS _____: New York 12533-6531

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Sir:

In compliance with the duty of disclosure under
37 C.F.R. § 1.56 and in accordance with the practice under
37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to
the documents listed on the enclosed Form PTO-1449. Copies of the
listed documents are also enclosed.

It is respectfully requested that the above information be
considered by the Examiner and that a copy of the enclosed Form
PTO-1449 be returned indicating that such information has been
considered.

Applicants undersigned attorney may be reached by telephone

FIS920030379US1

at (845) 894-6919. All correspondence should continue to be directed to the below listed address.

Respectfully submitted,



Todd M. C. Li
Attorney for Applicants
Registration No.45,554

INTERNATIONAL BUSINESS MACHINES CORPORATION
Intellectual Property Law Department
B/300-482
2070 Route 52
Hopewell Junction, New York 12533
Facsimile: (845) 892-6363

TML/kcm

SUPPLEMENTAL INFORMATION DISCLOSURE

Sheet 1 of 1

FORM PTO-1449 (Modified)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. & TRADEMARK NO.: FIS920030379US1	SERIAL NO.: 10/708,055
SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT		APPLICANT: Lars W. Liebmann et al.	
(Use several sheets if necessary) (37 CFR 1.98(b))		FILING DATE: 02-05-04	GROUP:

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUB- CLASS	FILING DATE IF APPROPRIATE
	AT						
	AU						
	AV						
	AW						
	AX						
	AY						
	AZ						

		U.S. PATENT APPLICATION NO.	PUBLICATION DATE	INVENTOR			
	BA	US2003/0056190A1	03/20/2003	Liu et al.			
	BB						
	BC						
	BD						

FOREIGN PATENT DOCUMENTS

			PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUB- CLASS	TRANSLATION	
		DOCUMENT NUMBER					YES	NO
	BE							
	BF							
	BG							
	BH							
	BI							

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	BJ	"Alternating Phase Shifted Mask for Logic Gate Levels, Design and Mask Manufacturing", Lars Liebmann, Ioana Graur, William Liepold, James Oberschmidt, David O'Grady and Denis Riegaill, IBM Microelectronics, 12 pages
	BK	
	BL	

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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